



User Information

Name of the user: _____

Email:

Phone Number:

Faculty/ Guide Name:

Faculty/ Guide Email:

Name of the Department: _____

Sample Information

Substrate:

Substrate Size:

Process Details Information

Minimum Feature size :

Maximum Feature size :

Resist required:

Sample Processing (For Fabrication)

Was the sample processed outside IITBNF?

☐ Yes ☐ No

Any sample processed at any labs outside IITBNF at any intermediate process step is considered as 'sample processed outside IITBNF'

Sample History *

[illegible]

Number of Samples: _____

Preferred Slots (Expected Week): _____

Process Description in detail * (Pls include resist details and recipe for litho)

We agree to acknowledge the Microwriter ML3 at IITBNF, Dept of Electrical Engineering,
Central Facility of IIT Bombay in our Publications/Reports/Thesis in which the data is used.

* Other details required would be communicated to the user depending on the submitted request.